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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10018049	FILING DATE 02/14/2002	CLASS 528	SUBCLASS	GAU 1711	EXAMINER CALEH
**APPLICANTS: Pirs Jan; Silva; Maric Bojan; Blinc Robert; Copic Martin; Petkovsek Rok;					
**CONTINUING DATA VERIFIED: THIS APPLICATION IS A 371 OF PCT/SI00/00017 06/12/2000					
** FOREIGN APPLICATIONS VERIFIED: SLOVENIA P-9900164 06/15/1999					
PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials				ATTORNEY DOCKET NO 5599	
TITLE : Process for the manufacturing of the polymer compensation layer for icd optical light shutter and the construction thereof					
U.S. DEPT. OF COM. / PAT. & TM-PTO-436L (Rev. 12-94)					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg.
		Print Fig.	
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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